

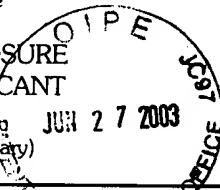
FORM PTO-1449 U.S. Department of Commerce
(Rev. 4/92) Patent and Trademark Office

ATTY. DOCKET NO.
APV31121

SERIAL NO.
09/702,084

INFORMATION DISCLOSURE
STATEMENT BY APPLICANT

(Use several sheets if necessary)



APPLICANT
Sivik et al.

FILING DATE
October 30, 2000

GROUP

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TC 170

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER							DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	5	7	8	3	5	3	3					
PN	4	4	5	4	0	6	0	06/84	Lai et al.	1	1	
	5	8	5	3	7	1	0	12/98	Dehan et al.	1	1	
	5	8	5	8	3	4	3	01/99	Szymczak			
	5	8	8	2	5	4	1	03/99	Achtmann			
↓	5	9	0	2	5	7	4	05/99	Stoner et al.			
PN	5	9	0	2	7	7	8	05/99	Hartmann et al.			

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER							DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
	5	6	0	5	6	7	8					YES	NO
PN	9	5	2	2	3	1	1	08/95	WO	1	1		
	9	7	2	9	7	3	6	08/97	WO				
	9	7	3	5	5	4	9	10/97	WO				
	9	9	1	5	3	2	1	06/99	AU				
	9	9	1	5	3	2	2	06/99	AU				
	0	3	0	8	1	9	0	03/89	EP				
	0	0	0	6	1	0	2	02/00	WO				
✓	9	8	3	8	9	7	3	09/98	WO				
PN	9	8	3	9	4	0	1	09/98	WO				

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

PN	US Patent Application No. 09/698,479 filed October 30, 2000 in the name of Yeung et al.
PN	US Patent Application No. 09/698,149 filed October 30, 2000 in the name of Yeung et al.

EXAMINER: *PN* DATE CONSIDERED 8/10/03

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EXAMINER INITIAL	DOCUMENT NUMBER								DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
	5	7	1	4	0	0	1	02/98		Savoly et al.				
	5	2	7	7	8	9	9	01/94	McCall					
	3	0	9	9	6	3	6	07/63	Skiles					
	4	3	0	4	7	0	3	12/81	Das					
	4	4	8	6	4	8	9	12/84	George					
	3	2	4	9	4	5	5	05/66	Williams					
	3	6	7	1	5	0	2	06/72	Samour et al.					
	4	5	2	8	1	1	1	07/85	Su					
	5	3	3	8	5	4	1	08/94	Matz et al.					
	5	5	8	0	8	1	9	12/96	Li et al.					
PN	4	8	3	5	2	1	1	05/89	Noda et al.					

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER							DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
	1	0	7	3	9	4	7					YES	NO
PN	1	0	7	3	9	4	7	06/67	GB				
	9	1	1	5	5	2	4	10/91	WO				
	9	8	0	1	4	7	8	01/98	WO				
PN	5	3	1	1	1	9	4	11/93	JP			Abstract Only	

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	3	9	6	0	7	6	3	06-76		Lambou et al				
	4	7	1	3	1	8	2	12-87	Hiltz et al					
	4	7	3	4	0	9	9	03-88	Cyprien					
	5	0	2	7	8	9	8	07-91	Naae					
	5	0	4	2	5	8	3	08-91	D'Souza et al					
	5	1	0	4	6	4	3	04-92	Grollier et al					
	5	1	6	9	4	4	1	12-92	Lauzon					
	5	2	1	8	0	2	1	06-93	Clark et al					
	5	2	3	2	6	3	2	08-93	Woo et al					
	5	3	4	6	6	9	9	09-94	Tiernan et al					
	5	4	1	5	8	6	0	05-95	Beucherie et al					
	5	4	9	6	4	7	5	03-96	Jho et al					
	5	5	3	6	4	5	2	07-96	Black					
	5	5	4	9	8	6	9	08-96	Iwakawa					
	5	5	8	7	0	2	2	12-96	Black					
	5	6	1	2	3	0	8	03-97	Woo et al					
	5	6	1	4	4	7	3	03-97	Dino et al					
	5	6	5	8	9	6	1	08-97	Cox, Sr.					
	5	6	6	5	4	6	6	09-97	Guez et al					
	5	6	8	6	0	2	4	11-97	Dahanayake et al					
	5	7	0	5	0	3	3	01-98	Gerard et al					
	5	7	0	6	8	9	5	01-98	Sydansk					
	5	7	3	5	9	5	5	04-98	Monaghan et al					
	5	8	2	1	2	0	3	10-98	Williamson					

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